



US00D401250S

# United States Patent [19]

[11] **Patent Number: Des. 401,250**

**Tudhope et al.**

[45] **Date of Patent: \*\*Nov. 17, 1998**

[54] **SHIELD AND COVER FOR TARGET OF SPUTTER COATING APPARATUS**

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[73] Assignee: **Semiconductor Equipment Technology**, San Jose, Calif.

[\*\*] Term: **14 Years**

[21] Appl. No.: **82,599**

[22] Filed: **Jan. 27, 1998**

[51] **LOC (6) Cl. .... 15-09**

[52] **U.S. Cl. .... D15/138**

[58] **Field of Search ..... D15/138; 204/298.02-298.11**

[56] **References Cited**

**U.S. PATENT DOCUMENTS**

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*Attorney, Agent, or Firm*—Gray Cary Ware & Freidenrich

[57] **CLAIM**

The ornamental design for a shield and cover for target of sputter coating apparatus, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of a shield and cover for target

of sputter coating apparatus embodying the design of the invention;

FIG. 2 is a top plan view of the shield and cover for target of sputter coating apparatus of FIG. 1;

FIG. 3 is a bottom plan view of the shield and cover for target of sputter coating apparatus of FIG. 1;

FIG. 4 is a side elevation view of the shield and cover for target of sputter coating apparatus as seen from the bottom of FIG. 2;

FIG. 5 is a side elevation view of the shield and cover for target of sputter coating apparatus as seen from the top of FIG. 2;

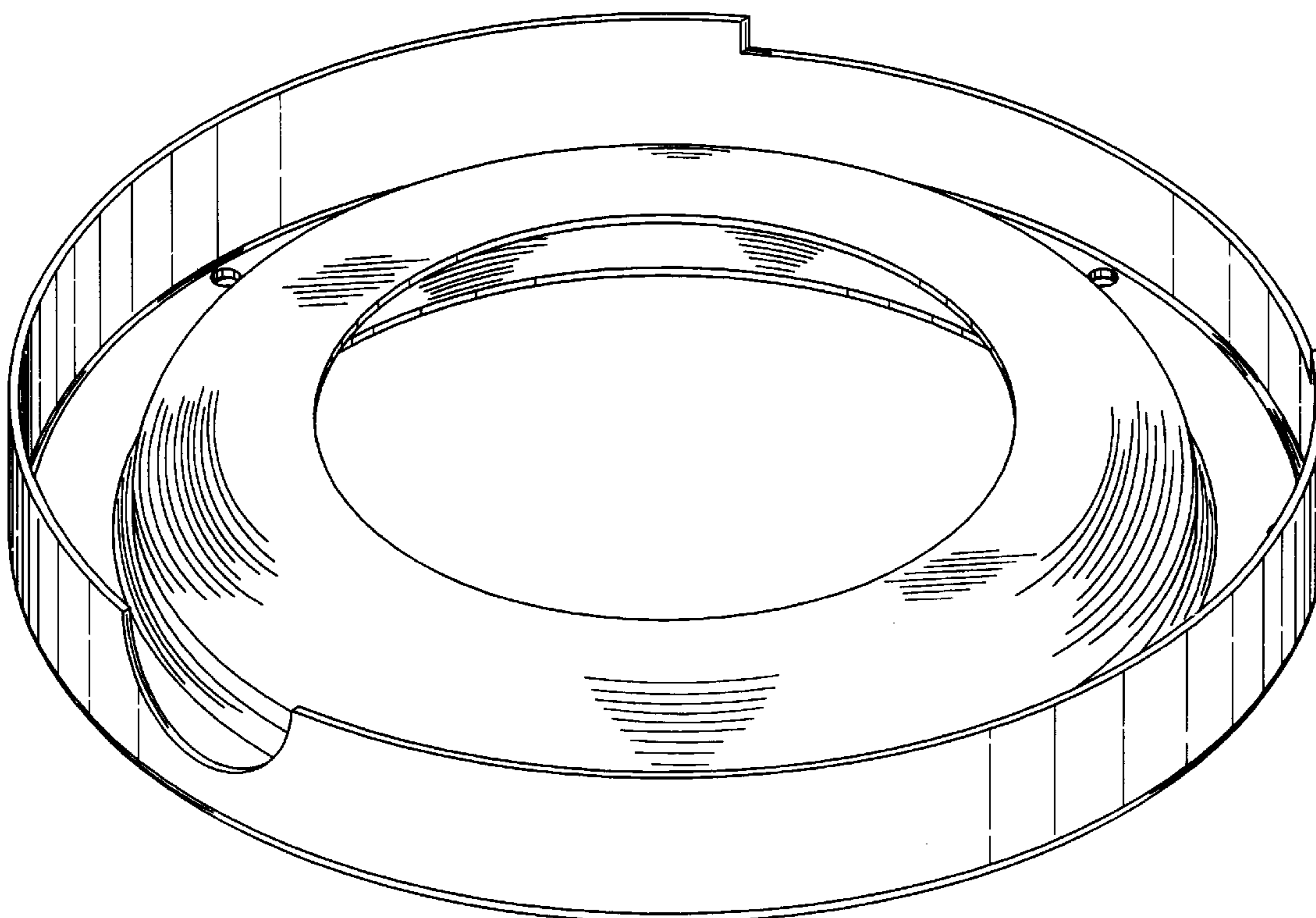
FIG. 6 is a side elevation view of the shield and cover for target of sputter coating apparatus as seen from the left side of FIG. 2;

FIG. 7 is a side elevation view of the shield and cover for target of sputter coating apparatus as seen from the right side of FIG. 2;

FIG. 8 is a cross-sectional view of the shield and cover for target of sputter coating apparatus taken along the line 8—8 of FIG. 2; and,

FIG. 9 is a cross-sectional view of the shield and cover for target of sputter coating apparatus taken along the line 9—9 of FIG. 2.

**1 Claim, 4 Drawing Sheets**



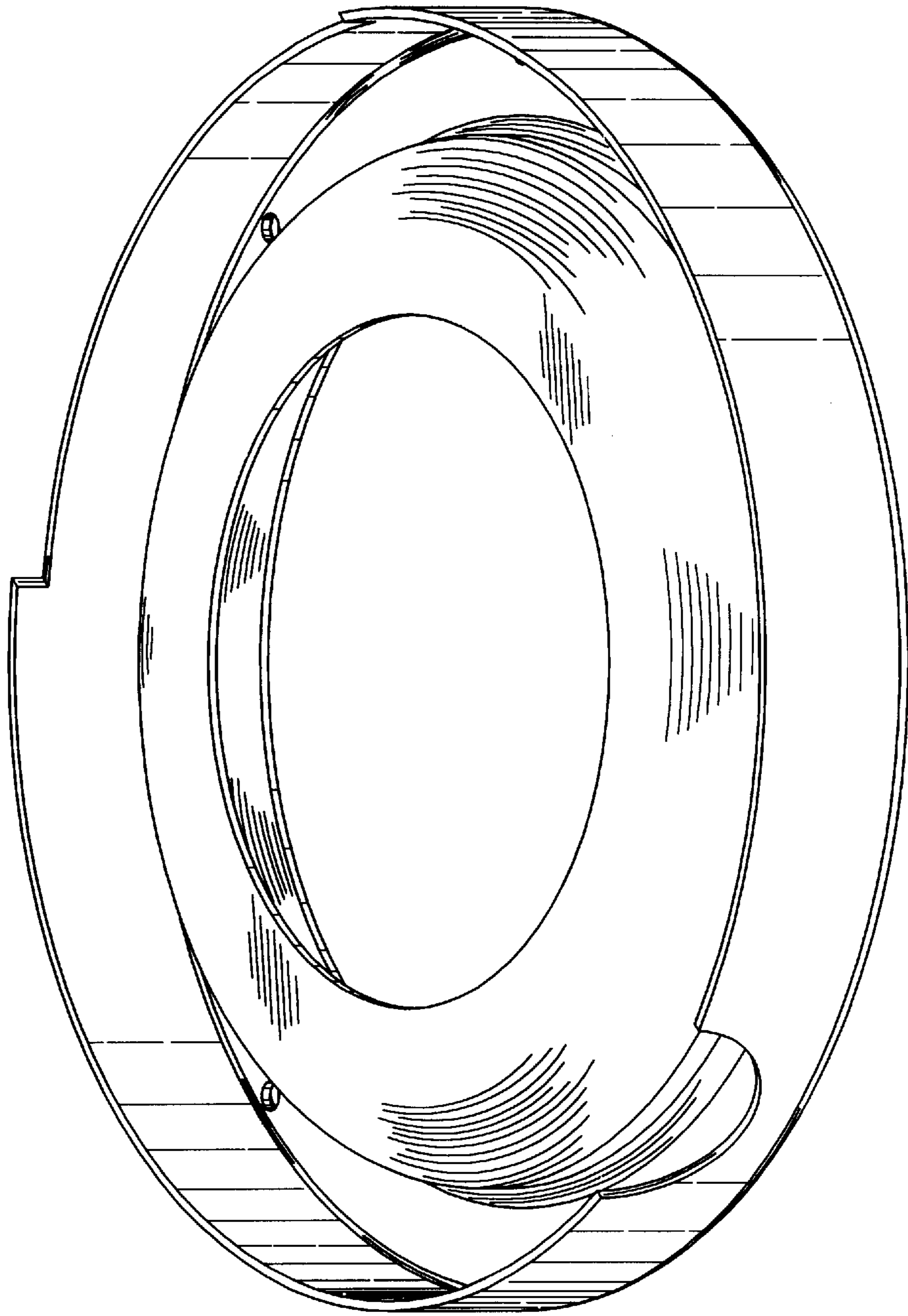


FIG. 1

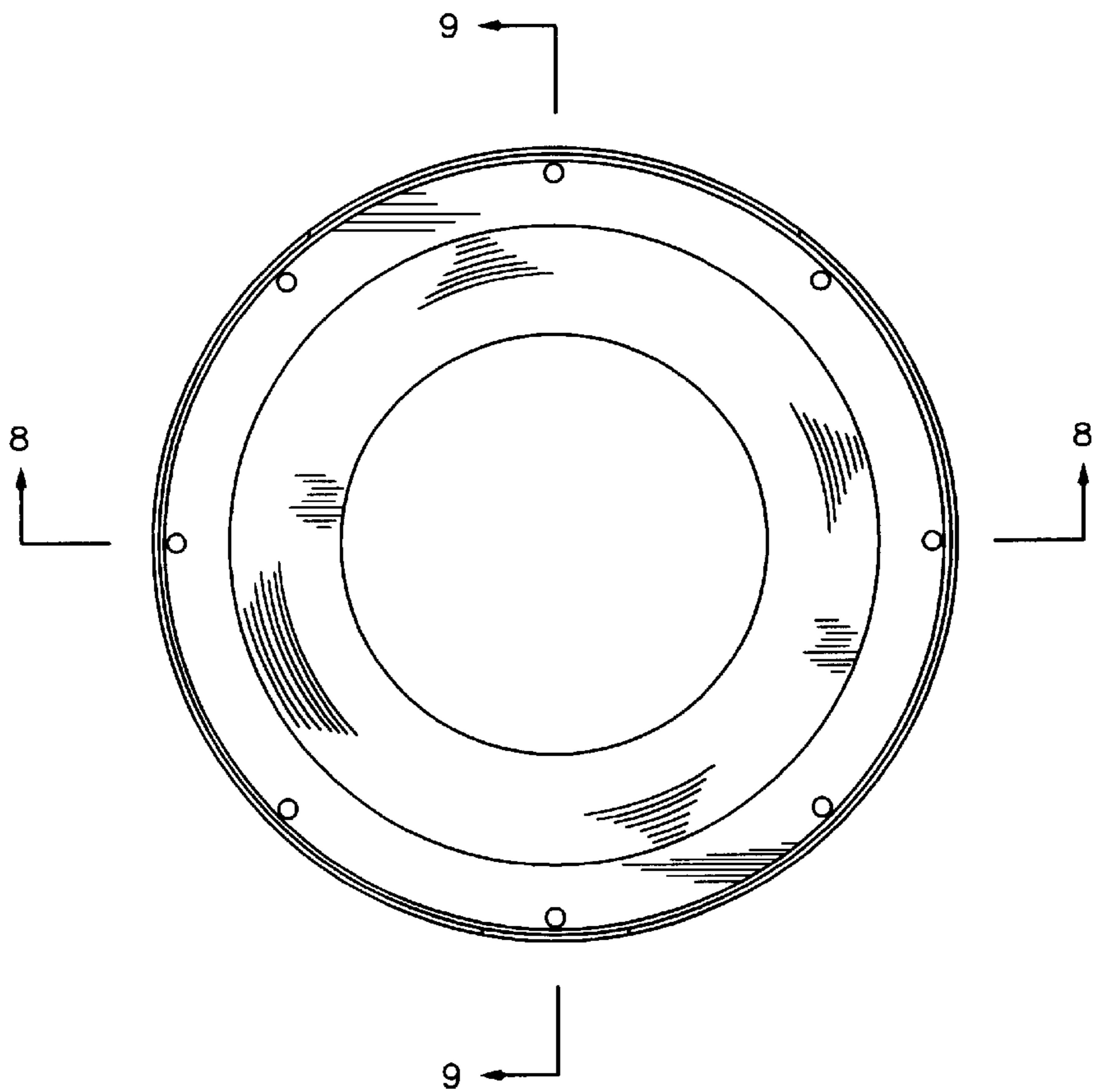


FIG. 2

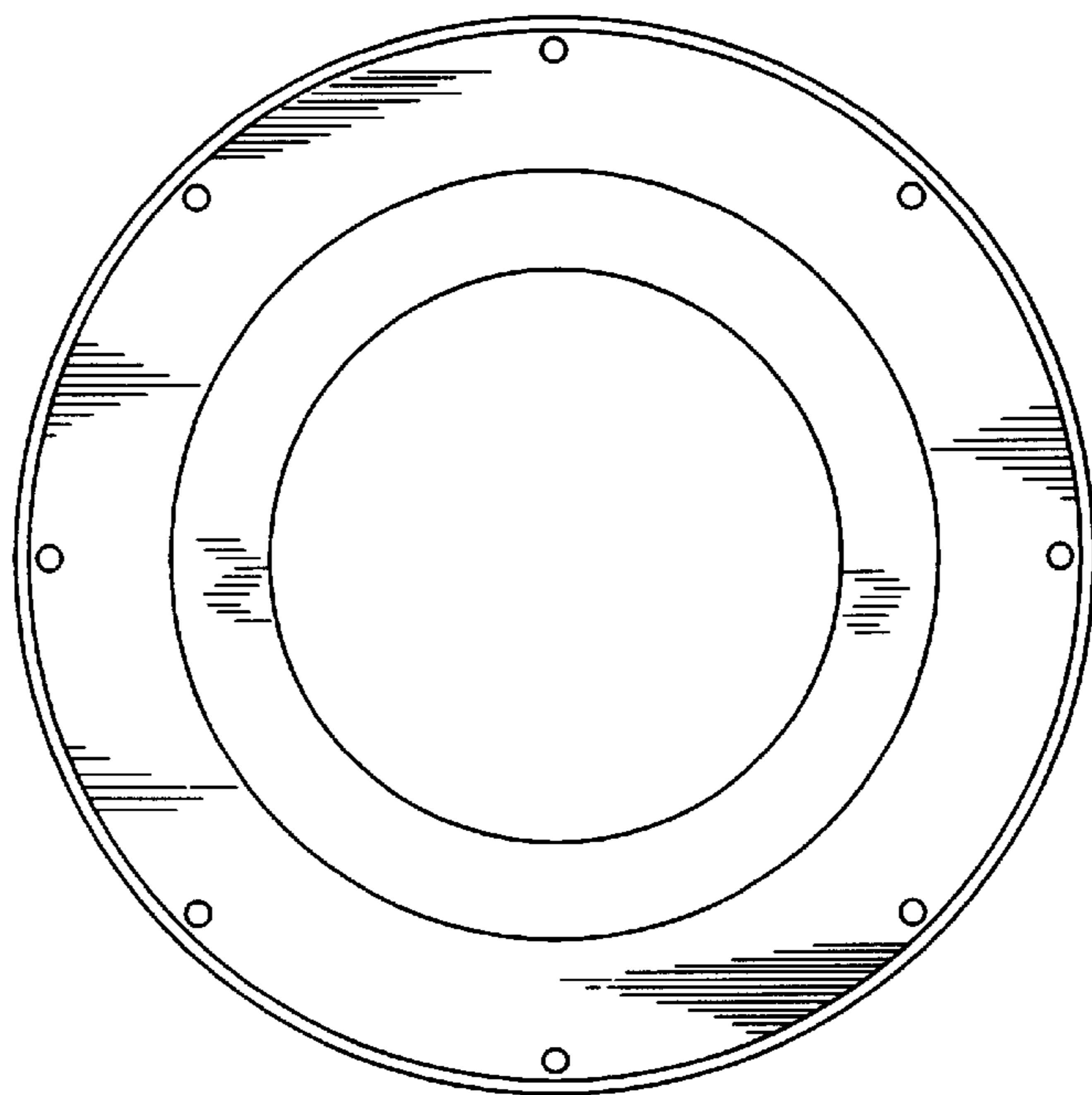


FIG. 3



FIG. 4

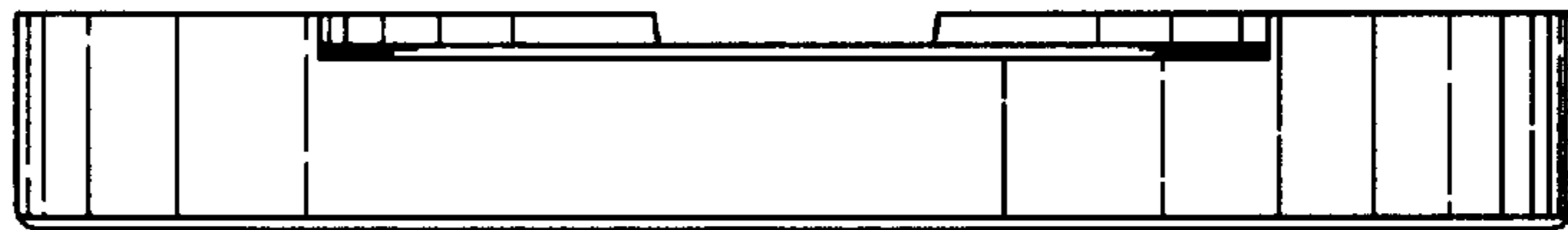


FIG. 5



FIG. 6

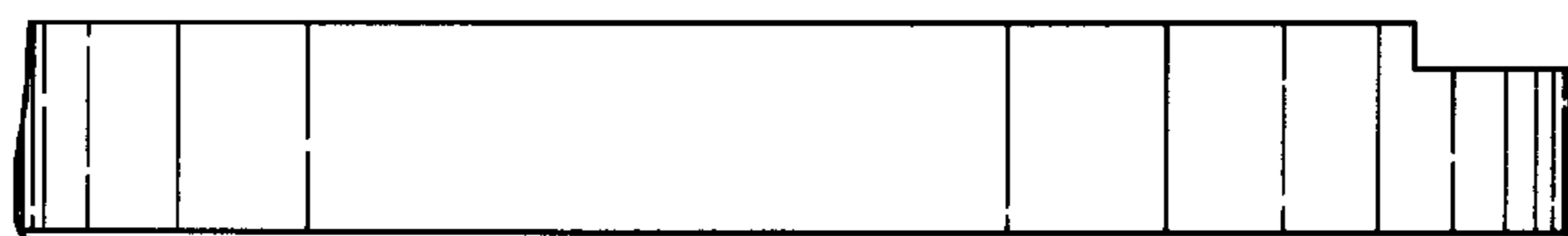


FIG. 7

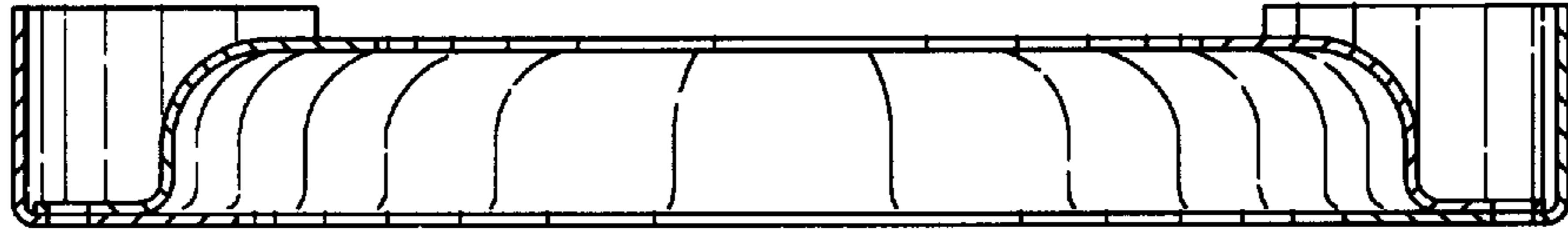


FIG. 8

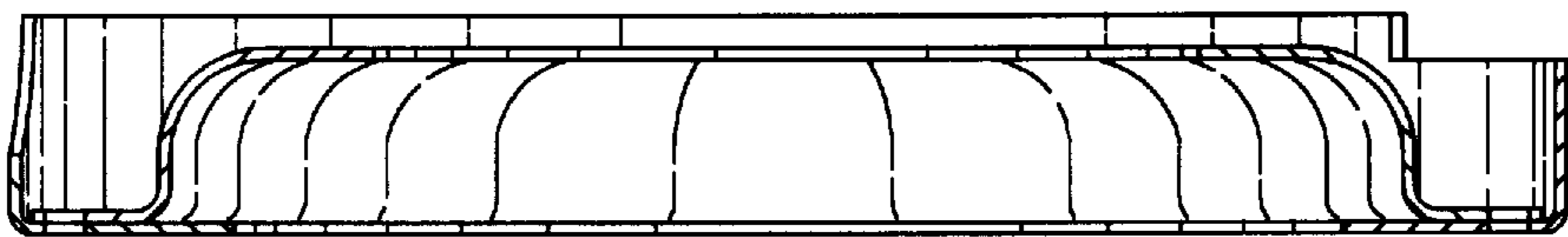


FIG. 9